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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/664,866	09/22/2003	Toru Takayama	0756-7201	4319
31780 7:	590 02/09/2006		EXAMINER	
ERIC ROBINSON		LE, THAO P		
PMB 955 21010 SOUTHBANK ST.			ART UNIT	PAPER NUMBER
POTOMAC FA	LLS, VA 20165		2818	

DATE MAILED: 02/09/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)					
	10/664,866	TAKAYAMA ET AL.					
Office Action Summary	Examiner	Art Unit					
	Thao P. Le	2818					
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
1) Responsive to communication(s) filed on 14 De	ecember 2005.						
2a) ☐ This action is <b>FINAL</b> . 2b) ☒ This	action is non-final.						
3) Since this application is in condition for allowan	ice except for formal matters, pro	secution as to the merits is					
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	3 O.G. 213.					
Disposition of Claims							
4)⊠ Claim(s) <u>1-14 and 16-22</u> is/are pending in the a	application.						
•	4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>1-14 and 16-22</u> is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/or	election requirement.						
Application Papers							
9) The specification is objected to by the Examiner	•						
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.							
Applicant may not request that any objection to the o	frawing(s) be held in abeyance. See	37 CFR 1.85(a).					
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11) ☐ The oath or declaration is objected to by the Exa	aminer. Note the attached Office	Action or form PTO-152.					
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).  a) All b) Some * c) None of:							
<ul> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No</li> </ul>							
3. Copies of the certified copies of the priority documents have been received in this National Stage							
application from the International Bureau (PCT Rule 17.2(a)).							
* See the attached detailed Office action for a list of the certified copies not received.							
Attachment(s)							
1) Notice of References Cited (PTO-892)	4) Interview Summary (	PTO-413)					
2) DNotice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Dat	e					
<ol> <li>Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)         Paper No(s)/Mail Date <u>1 page</u>.     </li> </ol>	5) Notice of Informal Pa	stent Application (PTO-152)					

#### **DETAILED ACTION**

Claims 1-14, 16-22 are pending.

### Information Disclosure Statement

Information Disclosure Statement (IDS) filed on **12/14/05** and made of record.

The references cited on the PTOL 1449 form have been considered.

### Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless --

(a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.

Claims 1, 3, 5-7 are rejected under 35 USC 102 (a) as being anticipated by Dairiki, U.S. Patent No. 6,599,818.

Regarding claims 1, 3, 5, 6, 7, Dairiki discloses a method for manufacturing a semiconductor device (See Figs. 4, 10A-10C, 11A-11C and Cols. 1-28) comprising: forming a semiconductor layer 202 over a glass substrate 201, forming an island-like insulating layer 203 over the semiconductor layer, forming an island-like light-absorbing layer 205/206 over the semiconductor layer 202 with the insulating layer 203/204 interposed therebetween, the island-like light-absorbing layer being capable of

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absorbing a pulsed light, performing a heat treatment for the semiconductor layer and the insulating layer by selectively heating the light-absorbing layer through an irradiation of the pulsed light, the light-absorbing layer covers the top face and the side face of the semiconductor layer and whose end portions are arranged outside of the semiconductor layer, forming a gate electrode 611a-614a (Fig. 10C) overlapping with the semiconductor layer by forming a metal layer over the light-absorbing layer and then performing an etching step (the gate electrode also serves as light-absorbing layer).

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 2, 4, 8-14, 16-22 are rejected under 35 U.S.C. 103(a) as being unpatentable over Dairiki, U.S. Patent No. 6,599,818.

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Regarding claims 2, 4, 8, 16, Dairiki discloses a method for manufacturing a semiconductor device (See Figs. 4, 10A-10C, 11A-11C and Cols. 1-28) comprising: forming a semiconductor layer 202 over a glass substrate 201, forming an island-like insulating layer 203 over the semiconductor layer, forming an island-like light-absorbing layer 205/206 over the semiconductor layer 202 with the insulating layer 203/204 interposed therebetween, the island-like light-absorbing layer being capable of absorbing a pulsed light, performing a heat treatment for the semiconductor layer and the insulating layer by selectively heating the light-absorbing layer through an irradiation of the pulsed light, the light-absorbing layer covers the top face and the side face of the semiconductor layer and whose end portions are arranged outside of the semiconductor layer, forming a gate electrode 611a-614a (Fig. 10C) overlapping with the semiconductor layer by forming a metal layer over the light-absorbing layer and then performing an etching step (the gate electrode also serves as light-absorbing layer ). Dairiki fails to disclose the length of the light-absorbing of one side is equal or less than a thickness of the glass substrate and wherein a transmission factor of a pulsed light by the island-like light-absorbing layer is 7- percent or less and a transmission factor of the pulsed light by the glass substrate is 70 percent or more. It would have been obvious to one having ordinary skill in the art that the length of the light-absorbing layer has to be equal or less than the glass substrate in order for the light-absorbing layer not to block all light and also to protect the glass substrate from over heated by the light. It would have been obvious to one having ordinary skill in the art at the time the invention was made that the selection of such parameters such as energy, concentration.

temperature, time, molar fraction, depth, thickness, etc., would have been obvious and involve routine optimization which has been held to be within the level of ordinary skill in the art. "Normally, it is to be expected that a change in energy, concentration, temperature, time, molar fraction, depth, thickness, etc., or in conbination of the <u>parameters</u> would be an unpatentable modification. Under some circumstances, however, changes such as these may impart patentability to a process if the particular ranges claimed produce a new and unexpected result which is different in kind and not merely degree from the results of the prior art ... such ranges are termed "critical ranges" and the applicant has the burden of proving such criticality.... More particularly, where the general conditions of a claim are disclosed in the prior art, it is not inventive to discover the optimum or workable ranges by routine experimentation." In re Aller 105 USPQ233, 255 (CCPA 1955). See also In re Waite 77 USPQ 586 (CCPA 1948); In re Scherl 70 USPQ 204 (CCPA 1946); In re Irmscher 66 USPQ 314 (CCPA 1945); In re Norman 66 USPQ 308 (CCPA 1945); In re Swenson 56 USPQ 372 (CCPA 1942); In re Sola 25 USPQ 433 (CCPA 1935); In re Dreyfus 24 USPQ 52 (CCPA 1934).

Regarding claims 11-12, 19-20, Dairiki doesn't disclose the pulsed light of the device. It would have been obvious to one having ordinary skill in the art at the time the invention was made that the selection of such parameters such as energy, concentration, temperature, time, molar fraction, depth, thickness, etc., would have been obvious and involve routine optimization which has been held to be within the level of ordinary skill in the art. "Normally, it is to be expected that a change in energy, concentration, temperature, time, molar fraction, depth, thickness, etc., or

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in conbination of the parameters would be an unpatentable modification. Under some circumstances, however, changes such as these may impart patentability to a process if the particular ranges claimed produce a new and unexpected result which is different in kind and not merely degree from the results of the prior art ... such ranges are termed "critical ranges and the applicant has the burden of proving such criticality.... More particularly, where the general conditions of a claim are disclosed in the prior art, it is not inventive to discover the optimum or workable ranges by routine experimentation." In re Aller 105 USPQ233, 255 (CCPA 1955). See also In re Waite 77 USPQ 586 (CCPA 1948); In re Scherl 70 USPQ 204 (CCPA 1946); In re Irmscher 66 USPQ 314 (CCPA 1945); In re Norman 66 USPQ 308 (CCPA 1945); In re Swenson 56 USPQ 372 (CCPA 1942); In re Sola 25 USPQ 433 (CCPA 1935); In re Dreyfus 24 USPQ 52 (CCPA 1934).

Regarding claims 9, 17, Dairiki discloses the light-absorbing layer is formed from a metal nitride (tantalum nitride, layer 611a-614a).

Regarding claims 10, 13, 14, 18, 21-22, Dairiki discloses the light source is from a xenon flash light. Dairiki also discloses the light source may be come from high pressure, halogen, halide lights. It is inherent that the light source disclosed in Dairiki is a coherent light.

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When responding to the office action, Applicants' are advice to provide the examiner with the line numbers and page numbers in the application and/or references cited to assist the examiner to locate the appropriate paragraphs.

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A shortened statutory period for response to this action is set to expire 3 (three) months and 0 (zero) day from the day of this letter. Failure to respond within the period for response will cause the application to become abandoned (see M.P.E.P 710.02(b)).

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thao P. Le whose telephone number is 571-272-1785. The examiner can normally be reached on M-T (7-6).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on 571-272-1787. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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